



DOCKET NO: 218781US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

ENTIRE APPLICATION OF :  
TAKEYOSHI SHIBASAKI, ET AL. : EXAMINER: NGUYEN, NGOC YEN M.  
SERIAL NO: 10/049,902 :  
FILED: JULY 8, 2002 : GROUP ART UNIT: 1754  
FOR: AMORPHOUS FINE SILICA :  
PARTICLE, ITS PRODUCTION PROCESS  
AND APPLICATION

SUPPLEMENTAL AMENDMENT

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

Further to the Amendment and Request for Continued Examination filed December 28, 2005, please amend the above-identified application as follows:

- Amendments to the Claims** begin on page 2 of this paper.
- Discussion of Amendment and Remarks** begin on page 6 of this paper.